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PATENT APPLICATION



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Eiji NATORI

Application No.: 09/819,688

Filed: March 29, 2001

Docket No.: 109120

For: METHOD AND DEVICE FOR MANUFACTURING CERAMICS, SEMICONDUCTOR  
DEVICE, AND PIEZOELECTRIC DEVICE

PRELIMINARY AMENDMENT

Director of the U.S. Patent and Trademark Office  
Washington, D. C. 20231

Sir:

Prior to initial examination, please amend the above-identified application as follows:

IN THE CLAIMS:

Please replace claims 31 and 33 as follows:

A1  
31. (Amended) A semiconductor device comprising a capacitor which includes a  
dielectric film formed by the manufacture method as defined in claim 1.

A2  
33. (Amended) A piezoelectric device comprising a dielectric film formed by the  
manufacture method as defined in claim 1.

REMARKS

Claims 1-33 are pending. Claims 31 and 33 are amended to eliminate multiple dependencies. Prompt and favorable consideration on the merits is respectfully requested.